	_	
Notice of Allowability	Application No.	Applicant(s)
	09/811,724	INOUE ET AL.
	Examiner	Art Unit
	Alina N. Boutah	2143
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this applied or other appropriate communication IGHTS. This application is subject to	plication. If not included will be mailed in due course. THIS
1. This communication is responsive to <u>7/13/06</u> .		
2. X The allowed claim(s) is/are 4-6,12-14,16 and 17.		
 3. Acknowledgment is made of a claim for foreign priority ur a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority do 	e been received. e been received in Application No	
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		complying with the requirements
4. A SUBSTITUTE OATH OR DECLARATION must be subminformal PATENT APPLICATION (PTO-152) which give		
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftspers	son's Patent Drawing Review (PTO-	948) attached
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b) including changes required by the attached Examiner' Paper No./Mail Date	s Amendment / Comment or in the C	Office action of
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the same of		
6. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT		
		·
Attachment(s)	- -	
1. Notice of References Cited (PTO-892)	5. Notice of Informal F	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary Paper No./Mail Da	
Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date	Paper No./Mail Da 7. ☐ Examiner's Amend	
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material		ent of Reasons for Allowance
	9. Other	ANDONE
	SUPERVISO TECHNOL	AVIDAVILLEY RYPATENT EXAMINER OGY CENTER 2100

Application/Control Number: 09/811,724

Art Unit: 2143

DETAILED ACTION

Response to Amendment

This action is in response to Applicant's amendment filed July 13, 2006. In response to the prior art rejection in the previous office action, Applicant has cancelled claims 19 and 20. Claims 4-6, 12-14 and 16-17 are pending in the present application.

Allowable Subject Matter

Claims 4-6, 12-14, 16 and 17 are allowed as previously indicated in the Office Action dated October 11, 2005.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alina N. Boutah whose telephone number is 571-272-3908. The examiner can normally be reached on Monday-Friday (9:00 am - 5:00 pm).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David A. Wiley can be reached on 571-272-3923. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Application/Control Number: 09/811,724

Art Unit: 2143

Page 3

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

ANB

ANB

DAVID WILEY
SUPERVISORY PATENT EXAMINER
TECHNOLOGY CENTER 2100